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U.S. UTILITY Patent Application

**PATENT NUMBER and
ISSUE DATE**

APPL NUM 10025304	FILING DATE 12/19/2001	CLASS 438	SUBCLASS 2822	GAU 2842	EXAMINER J. P. ALL
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****CONTINUING DATA VERIFIED:**

**** FOREIGN APPLICATIONS VERIFIED:**

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>	ATTORNEY DOCKET NO 01-377/LS11P180
Foreign priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no			
35 USC 119 conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no			
Verified and Acknowledged Examiners's initials			
TITLE : Method of preventing resist poisoning in dual damascene structures			

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
Assistant Examiner		DRAWING	
		Sheets Drwg.	Figs. Drwg.
Primary Examiner		Print Fig.	
PREPARED FOR ISSUE		Application Examiner	
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